

Gas sensing application of nanocrystalline zinc oxide thin films prepared by spray pyrolysis

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Abstract. Nanocrystalline oxygen-deficient ZnO thinfilm sensors were prepared by spray pyrolysis technique using zinc acetate dissolved in propanol and water as precursor. Response of the sensor to target gases NO₂ and H₂S is studied. At optimum temperature of 200°C, the sensors have a response of 3.32 to 7 ppm NO₂ and 1.4 to 18 ppm of H₂S gas. The analytical characterizations of the prepared sensors were performed using X-ray diffraction measurement, scanning electron microscopy, energy-dispersive X-ray spectroscopy and Raman spectroscopy. Dynamic response of sensors to different concentrations of NO₂ and H₂S gas was tested at optimum temperature. Experimental data revealed the sensors to be more selective to NO₂ gas with satisfactory response and recovery time.

Keywords. ZnO; thin film; spray pyrolysis; gas sensor; NO₂; H₂S.

1. Introduction

Monitoring air quality has become a priority due to the great amounts of pollutants released in the atmosphere, which have a toxic effect on ecosystem. To detect pollutant gases different kinds of sensor have been developed, i.e., electrochemical sensors,¹ polymer sensors,² surface acoustic wave (SAW) sensors³ and metal oxide semiconductor (MOS) sensors.⁴ The last ones are being preferred mainly because of their simplicity, small dimension and low cost. Conductometric metal oxide gas sensors rely on changes of electrical conductivity due to the interaction with the surrounding atmosphere.⁵ In 1991, Yamazoe⁶ demonstrated that reduction in crystal size would significantly increase the sensor performance. Nano-sized grains of metal oxides are almost depleted of carriers (most carriers are trapped in surface states) and exhibit much poorer conductivity than micro-sized grains in ambient air; hence, when exposed to target gases, they exhibit greater conductance changes as more carriers are activated from their trapped states to the conduction band than with micro-sized grains. Moreover, the large surface to volume ratio of nanomaterials exhibits high sensitivity to target gases. Hence, in the recent years, researchers are working towards the development of MOS nanomaterial-based sensor elements with improved sensing performance.

ZnO is a material with a variety of potential applications such as electronics,⁷ photonics,⁸ acoustics,⁹ TCO layer in solar cell^{10,11} and sensing.¹² On the electronic side, ZnO holds some potential in transparent thin film transistors owing to its high optical transmittivity and high conductivity. In optical emitters, its high exciton binding energy (60 meV)¹³ gives ZnO an edge over other semiconductors such as GaN.¹⁴ Due to its large electrochemical coupling, ZnO has significant applications in acoustic wave devices as SAW filter. As a gas sensing material, it is one of the earliest discovered and the most widely applied oxide gas sensing material.¹⁵ ZnO-based elements have attracted much attention as gas sensors because of their chemical sensitivity to different adsorbed gases, high chemical stability, amenability to doping, nontoxicity and low cost. Over the years various researchers have used different forms of ZnO for the detection of many gases. Pure and doped ZnO films prepared by different methods were found to be sensitive to H₂S gas.^{16–20} ZnO-based gas sensors were also found to be suitable for detection of gases like methane,^{21,22} formaldehyde,^{23–25} ethanol,^{26–29} ammonia,^{30–34} LPG,^{35–37} methanol,³⁸ propanol,^{38,39} and NO₂.^{18,40–44}

In the present context we report the NO₂ and H₂S gas sensing characteristics of oxygen-deficient nanocrystalline zinc oxide films prepared by chemical spray pyrolysis (CSP) technique on glass substrates. Sensor behaviour is presented in detail for a representative concentration for 7 ppm NO₂ and 18 ppm H₂S gas. Gas sensing performance of the sensors to test gases was investigated in the temperature range of 100–225°C.

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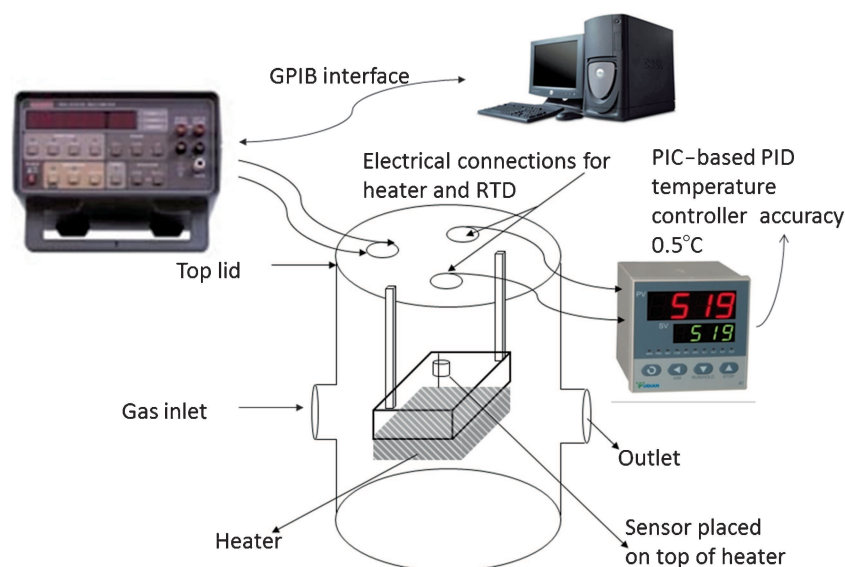


Figure 1. Schematic representation of static test system.

2. Materials and methods

2.1 Film preparation

Zinc oxide thin films were prepared on soda lime glass substrate using CSP technique. Zinc acetate solution (0.3 M) was prepared in a mixture of propanol and water, taken in the volume ratio 1:1. This precursor was selected due to its high vapour pressure at low temperature. Addition of few drops of acetic acid prohibits the precipitation of zinc hydroxide, thereby making the spray solution clear and producing films of better optical transmittance. Quantity of acetic acid added to the solution is also a key parameter in the film deposition process. Compressed air was used as the carrier gas (pressure ~ 0.34 bar) and temperature of substrate was kept at $450 \pm 5^\circ\text{C}$. Now keeping the molarity of zinc acetate ($\text{Zn}(\text{CH}_3\text{CO}_2)_2 \cdot 2\text{H}_2\text{O}$) at 0.3 M and spray rate at 7 ml min^{-1} , deposition was done using automated spray machine in which the spray rate, deposition time and movement of the spray head were controlled by a microprocessor. After the deposition, samples were quickly removed from the substrate heater.⁴⁵ ZnO films were deposited with $\sim 550 \text{ nm}$ thickness over 30 cm^2 area. ZnO films for gas sensing application were selected after optimizing the various parameters like spray rate, molarity, oxygen stoichiometry and thickness.^{46–48} Prior to gas sensing measurements, the films were annealed at an approximate temperature 600°C overnight (Actual temperature at the sample was within a range of 5% of this set temperature.) to remove any possible organic residue remained from the precursor solution and also to improve the crystallinity and to sinter the layer. High temperature annealing also helps in avoiding posterior instabilities, as these sensors are to be operated at elevated temperatures. For the purpose of gas sensing investigations, the films were cut into small pieces with an approximate area of 1 cm^2 .

2.2 Gas sensing measurement setup

The gas sensing measurements of the thin film sensor were carried out on custom-built static gas characterization system. The schematic representation of test system is shown in figure 1. The test system consists of a stainless steel chamber of diameter 7.5 and 6.35 cm height. The effective volume of the chamber is 280 ml. An inlet is provided for inserting the desired concentration of the gas to the chamber. The gas is injected into the test chamber with a syringe through the inlet provided with septum. Electrical connections from the sensor are taken with the help of two thin copper wires, bonded to the sensor with silver paint. The distance between the two electrodes is adjusted to 5 mm. The sensing capability of the sensor is characterized at different operating temperatures with a precisely controlled heater ($\pm 0.5^\circ\text{C}$) inside the system, to find out the optimum working temperature. Resistance change of the sensor on introduction of the test gas into the chamber is measured using computer-controlled Keithley 195A digital multimeter. Gas concentration is measured by taking required amount of gas from the obtained precalibrated cylinder (Chemtron Science Laboratories) in a syringe and then injecting it into the chamber pre-filled with air at atmospheric pressure. The response of the sensor was studied at different operating temperatures in the range $100\text{--}225^\circ\text{C}$ for various concentrations of NO_2 and H_2S gas ranging from 1.5 to 30 ppm and 5 to 60 ppm in air, respectively.

2.3 Characterization of the ZnO film

The crystalline structure and particle size of annealed thin film sensor were examined by X-ray diffraction measurement (XRD, Bruker AXS D8 Advance). Surface morphology of the prepared sensors were analysed using scanning

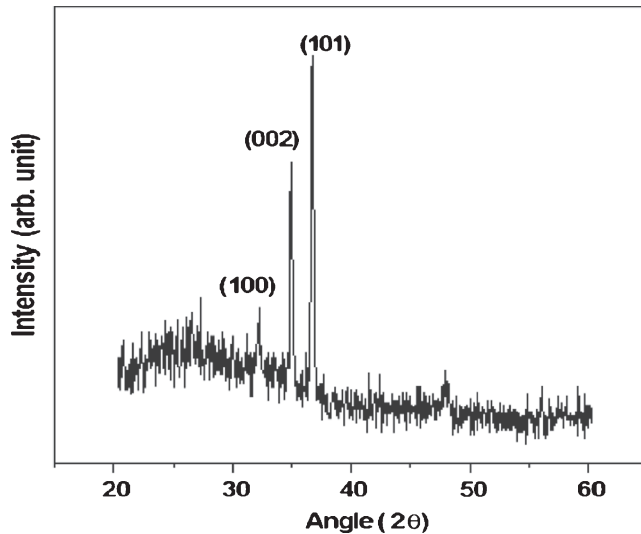


Figure 2. XRD pattern of annealed ZnO thin film sensor.

electron microscopy (SEM, JEOL Model JSM-6390LV). Elemental composition of the sensors was performed using energy-dispersive X-ray spectroscopy (EDS, JEOL Model JED-2300). Raman scattering measurements were obtained using Horiba Jobin Yvon LabRam HR system at a spatial resolution of 2 mm in a backscattering configuration. The 514.5 nm line of argon ion laser was used for excitation.

3. Result and discussion

3.1 XRD

Crystalline structure analysis of the prepared sensors was performed using XRD. Figure 2 shows the XRD pattern of annealed sensor. All peaks can be confirmed to correspond to the hexagonal wurtzite structure of ZnO (JCPDS No. 36-1451). Main reflections were obtained in the (30° – 40°) 2θ range corresponding to (100), (002) and (101) planes, the (101) plane being prominent. Under the reactive conditions adopted in our experiments, the ZnO films tend to grow along the maximum density (101) plane. Earlier reports by Fan *et al.*⁴⁹ proved that the presence of thin film stress can alter the energetic balance between (002) and (101) orientations and lead to preferred (101) texture in certain conditions.^{49,50}

The crystallite size (D) was calculated from peak broadening using the Scherrer approximation, which is defined as

$$D = \frac{0.9\lambda}{B \cos \theta}, \quad (1)$$

where λ is the wavelength of the X-ray (1.5418 \AA), B the full-width at half maximum (FWHM, radian) and θ the Bragg angle (degree). The crystallite sizes were calculated using FWHM of the peaks corresponding to the planes (100), (002) and (101). The average crystallite size was found

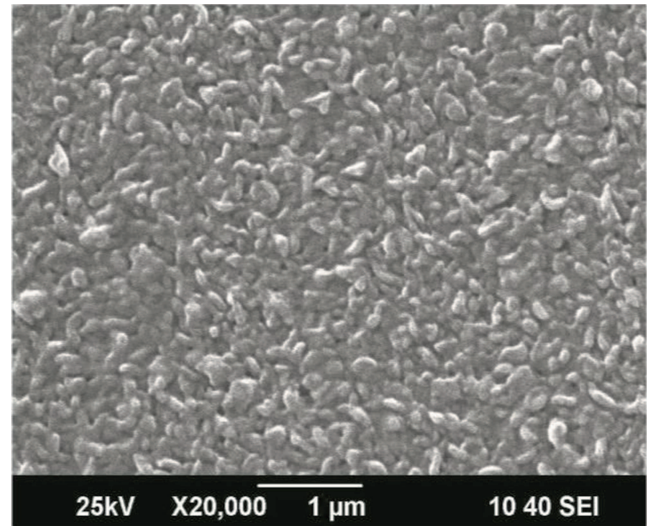


Figure 3. SEM images of annealed ZnO thin film sensor.

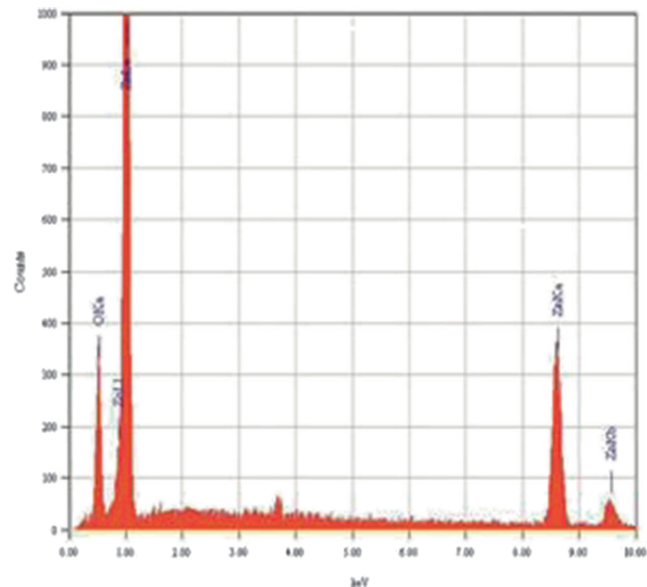


Figure 4. EDS spectrum of annealed ZnO thin film sensor.

to be 38 nm. The XRD studies confirmed the nanocrystalline nature of thin film sensor.

3.2 SEM and EDS

SEM image of the annealed sensor shown in figure 3 revealed a closely packed arrangement of crystallites. Particles with not much definite shape were revealed in the SEM images of annealed thin film sensor. The EDS analysis of sensor is shown in figure 4. EDS analysis of annealed ZnO film shows that zinc and oxygen are the only detected elements. The SEM image provided a rough representation of the annealed thin film sensor. The EDS analysis performed proved that the prepared sensor film composed of zinc and oxygen

elements only. The XPS analysis performed on the ZnO film is reported elsewhere.⁴⁵

3.3 Raman spectroscopy

Raman spectrum of annealed thin film sensor is shown in figure 5. Raman spectroscopy gives information on vibrational properties of ZnO.⁵¹ It is known for wurtzite-type ZnO (space group $p6_3mc$) that optical phonons at the Γ point of the Brillouin zone belong to the following irreducible representation: $\Gamma = A_1 + E_1 + 2E_2 + 2B_1$, where A_1 and E_1 modes are both Raman and infrared active, E_2 modes are Raman active only and B_1 modes are both Raman and infrared inactive (silent modes).^{13,52–54} Nonpolar E_2 phonon modes have two frequencies; the low frequency E_2 mode (E_2^{low}) and high frequency E_2 mode (E_2^{high}). The E_2 modes at low and high frequencies are at 101 and 437 cm^{-1} , respectively. The low frequency E_2 mode (E_2^{low}) is associated with vibration of the Zn sublattice, while the high frequency E_2 mode (E_2^{high}) is related to the vibration of oxygen atoms.^{55,56} E_2^{high} of ZnO is the strongest mode in the wurtzite crystal structure. The strong E_2 (high) mode indicates a good crystallinity.⁵⁷ Peak at 556 cm^{-1} is a contribution of the E_1 (LO) mode of ZnO in the case of oxygen deficiency.^{58,59} Such a strong intensity of 556 cm^{-1} E_1 mode demonstrates that ZnO thin film sensor is oxygen deficient. These oxygen-deficient sites can enhance the gas sensing properties of thin film sensor. An additional peak is obtained at 330 cm^{-1} . Peak at the same position was reported earlier in literature by various researchers.^{60–62} This peak is assigned to possible multiple-phonon-scattering. The above presented results confirmed the ZnO hexagonal wurtzite structure, which is in good agreement with the obtained XRD results.

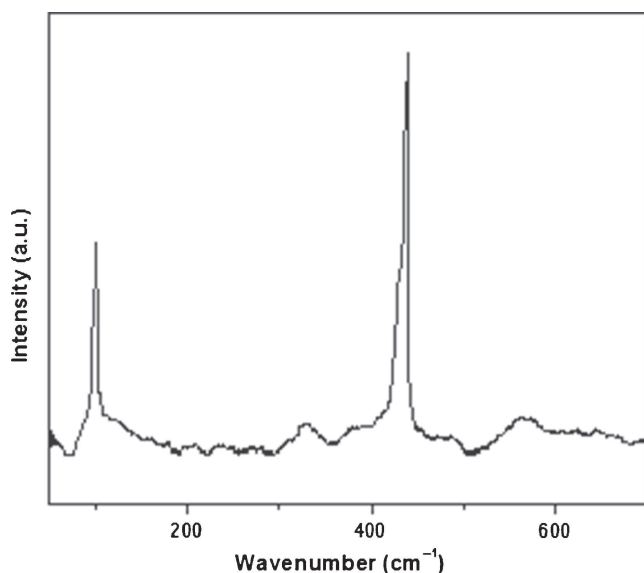


Figure 5. Raman spectra of annealed ZnO thin film sensor.

3.4 Gas sensing investigations

The gas sensing properties of thin film ZnO sensor was studied in a static gas sensing test system with an effective volume of 280 ml. Sensitivity of the active layer upon oxidizing NO_2 gas exposure is measured in terms of the ratio $S = R_{\text{gas}}/R_{\text{air}}$ and for reducing gas (H_2S), S is given as $R_{\text{air}}/R_{\text{gas}}$, where R_{gas} is resistance of sensor in presence of gas and R_{air} is resistance of sensor before introduction of gas. The temperature-dependent sensitivity of sensors was studied in the range of 100–225°C. Below the sensor temperature of 100°C, it was difficult to measure gas sensing characteristics due to the sluggish recovery kinetics. Relatively low concentration 7 ppm of NO_2 and 18 ppm H_2S gas investigation is presented in detail. Similar results were obtained for higher concentration studied. Figure 6a and b represents temperature-dependent sensitivity of sensor to a concentration of 7 ppm NO_2 gas and 18 ppm H_2S gas studied.

NO_2 response of sensor to 7 ppm presents a maximum sensitivity at 200°C as the temperature increases from 100 to 225°C, the sensor sensitivity increasing from 1.22 to 3.32, which is the maximum. Increasing the temperature above

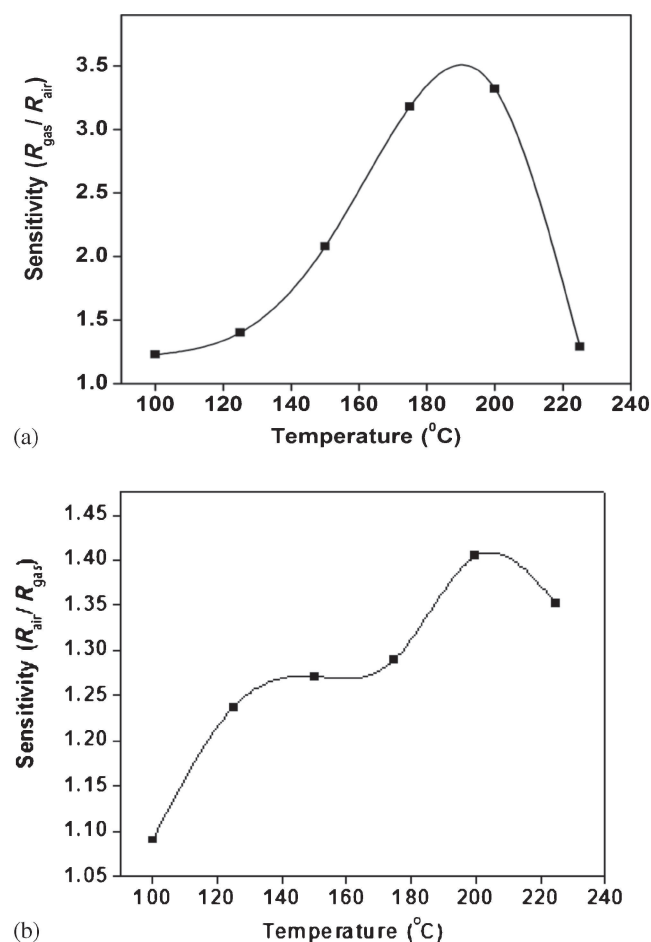


Figure 6. Sensitivity of ZnO thin film sensor towards (a) 7 ppm of NO_2 gas (b) 18 ppm of H_2S gas at different temperatures.

200°C decreases sensor sensitivity, achieving 1.29 at 225°C. Concerning the 18 ppm H_2S sensor response, sensitivity increases with increase of temperature in the studied range, attaining a maximum 1.4 at 200°C. Increasing the temperature more than 200°C, the sensitivity decreases and attains 1.15 at 225°C. Considering the temperature-dependent sensitivity studies, optimal operating temperature of 200°C was chosen to further examine the characteristics of the gas sensor to NO_2 and H_2S gas. Comparing the maximum sensitivity values (3.32 for 7 ppm NO_2 and 1.4 for 18 ppm H_2S), ZnO sensor is more sensitive to NO_2 at lower concentration and operating temperature. Figure 7a and b shows response of sensor to 7 ppm NO_2 and 18 ppm H_2S gas at 200°C, respectively.

The maximum sensitivity of ZnO being obtained at 200°C, the dynamic responses of ZnO thin film gas sensor at 200°C were tested with different NO_2 concentrations at 1.5, 3.5 and 30 ppm, respectively. Figure 8 represents the dynamic response of sensor to different NO_2 gas concentration studied. Dynamic responses of the sensor to 5, 10, 30 and 60 ppm concentration of H_2S gas were performed at the

optimum operating temperature of 200°C. Figure 9 represents the dynamic response of the sensor to H_2S gas at 200°C to various concentrations.

Chemoresistivity is the basis of sensing mechanism for metal oxides, which consists of a variation of intergranular and intragranular barriers with subsequent conductance change, as a response to surface chemical reactions with environmental gases. ZnO-based gas elements prepared in nanocrystalline form have large numbers of grain boundaries and necks. The adsorbed oxygen on the grain surface extracts the conduction electrons from near-surface region of the grain, leading to the grain-boundary barriers and the neck barriers.⁶³ The neck barrier controls the electron conducting channel through the neck and the electron density in the space charge layer at the neck.⁶⁴ Therefore the neck barrier

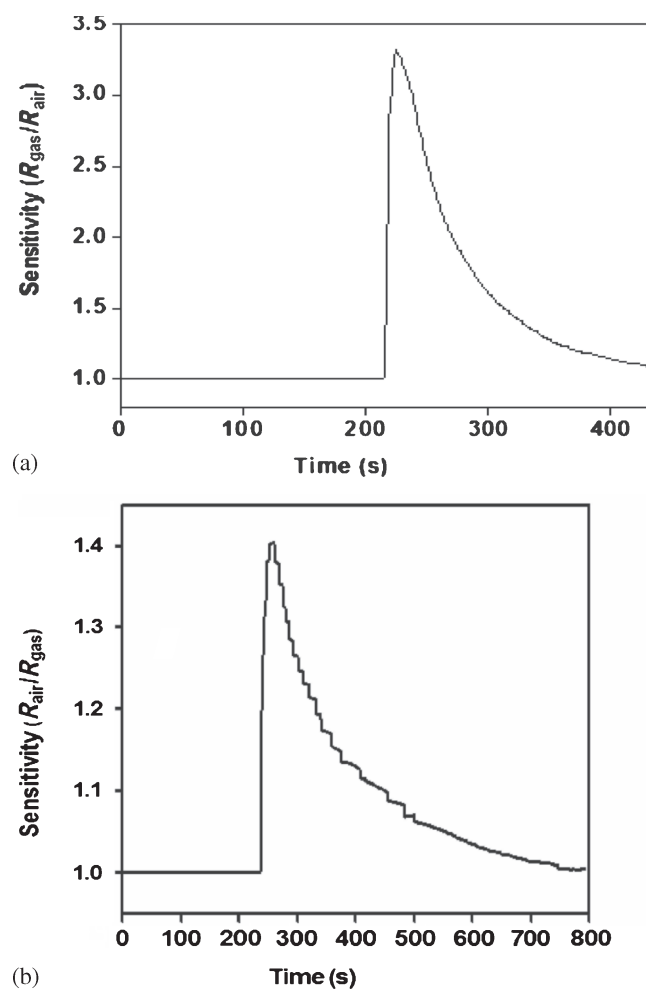


Figure 7. Response of ZnO thin film sensor to (a) 7 ppm NO_2 gas and (b) 18 ppm H_2S gas at 200°C.

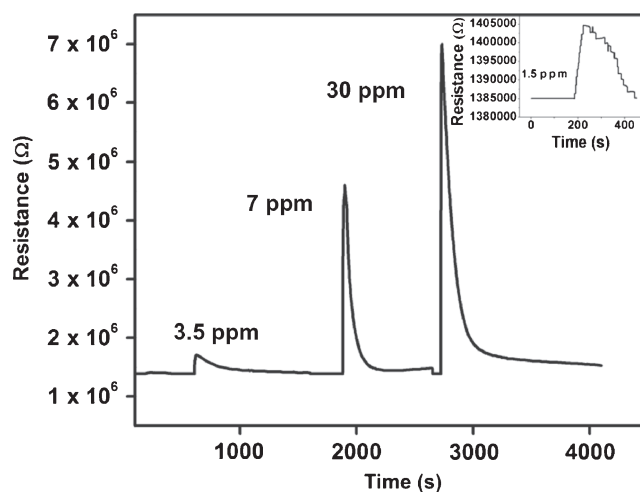


Figure 8. Dynamic response of ZnO thin film sensor to different NO_2 gas concentrations studied.

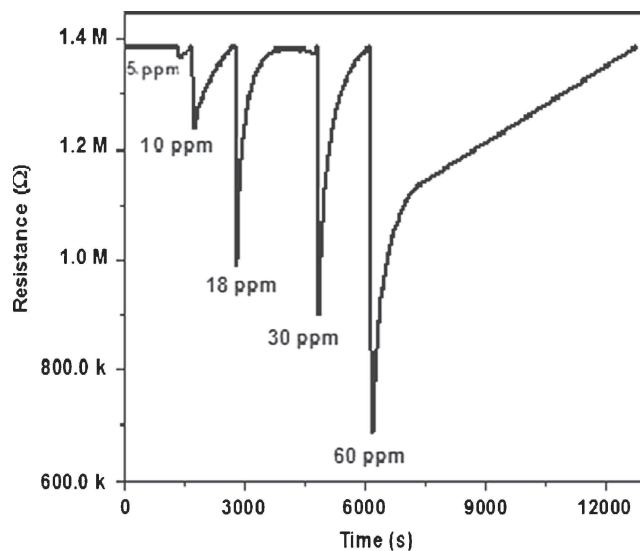


Figure 9. Dynamic response of thin film sensor to different H_2S gas concentrations studied.

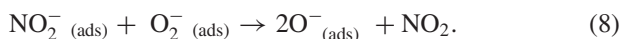
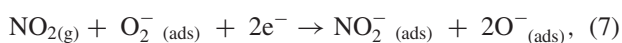
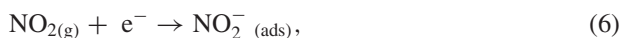
determines the neck resistance. At the same time, the grain-boundary barrier determines the grain-boundary resistance. Ma *et al*⁶³ studied the effect of grain size on gas sensitivity on ZnO.⁶⁵ This group described the total sensitivity in ZnO-based nanocrystalline sensors is the effect of both neck and the neck–grain boundary resistance. Gupta *et al*⁶⁵ studied the sensitivity of ZnO-based gas sensors to NO and H₂S gas. The results demonstrate that response of ZnO sensors to H₂S arises from grain boundary only, whereas both grain boundaries and intra-grain resistances contribute towards response to NO. As XRD studies confirmed the nanocrystalline nature, a similar effect is expected in our sensors to NO₂ and H₂S gases. However, detailed investigations like impedance spectroscopy measurements are to be carried out to confirm these findings.

Oxygen vacancies and defects in lattice act as adsorption sites for oxygen and test gases. As the detection of gases originates from interaction of these adsorbed oxygen atoms with gases, maximum (minimum) defect density in (polycrystalline material) yields maximum (minimum) response.⁶⁵ Raman spectroscopy performed on our sensors revealed that the thin film sensors prepared are oxygen deficient. These oxygen vacancies in the sensors act as additional sites for gas adsorption, thereby enhancing the sensitivity.

Earlier research works conclude, oxygen adsorbed on the surface of oxide gas sensors undergoes the following reactions given by⁶⁶ eqs (2–5).



At low temperatures, O₂[−] is commonly chemisorbed. At high temperatures, however, O[−] and O^{2−} are chemisorbed while O₂[−] disappears.⁶⁷ The oxygen ionosorption removes conduction electrons and thus lowers the conductance of ZnO.⁶⁷ The reactive oxygen species such as O^{2−}, O₂[−] and O[−] are first adsorbed on ZnO surface when temperature rises. When the sensor film is exposed to NO₂, which is an oxidizing gas, the molecules can be directly adsorbed onto the surface by extracting electrons from the conduction band (eq. (6)) or they can interact with the chemisorbed oxygen on the surface (eqs (7 and 8))

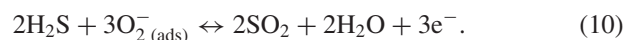


As shown in above equations the electrons are consumed in the reactions, which explain the increase of the ZnO resistance after the NO₂ exposure. The adsorption of O₂[−] ions is a very interesting and critical phenomenon in metal-oxide gas

sensor, because the O₂[−] ions tend to assist the adsorbed NO^{2−} ions in taking the electrons from the ZnO thin films.

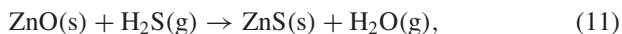
The optimum operating temperature for pure and doped sensors was found to be 200°C for NO₂ gas. At lower temperature the sensitivity was low; also the recovery time kept on increasing, which indicates a longer time taken by the sensor to revert back to its base-line properties for the next operation. At low operating temperature sensitivity of the films to NO₂ is restricted by the speed of the chemical reaction, because the electrons do not have enough thermal energy to react with the surface adsorbed oxygen species. In fact, during adsorption of atmospheric oxygen on the film surface, a potential barrier to charge transport is developed. As operating temperature increases the thermal energy obtained is high enough to overcome the potential barrier and thus electron concentration increases significantly, which in turn leads to an increase in sensitivity of sensor films. At optimum operating temperature the sensitivity is maximum. This is attributed to the availability of sufficient adsorbed ionic species of oxygen on film surface, which react most effectively with NO₂ molecules at this particular temperature. The results obtained for NO₂ gas sensing is comparable with earlier published results.^{68,69}

A reverse effect is observed when the sensor films are exposed to H₂S gas, a decrease of the ZnO film resistance under H₂S exposure, which can be explained by its reaction with chemisorbed oxygen (eqs (9 and 11)), inducing the release of electrons in the conduction band.⁷⁰ The gas response by MOS, in general, can be described as



This reaction shows an increase in the number of electrons (the reaction infuses electrons into sensing layers), thereby decreasing the sensor resistance. In addition to surface reaction with adsorbed oxygen species, chemical conversion of ZnO with H₂S is another possible reaction mechanism affecting conductivity of ZnO sensor. The chemical conversion of gas sensing materials through the direct reaction with target gas is known to be an important mechanism that changes the conductivity and produces a high sensitivity in several sensing materials of metal oxides. The chemical conversion of CuO nanoparticle to metallic copper sulphide (CuS) has been reported in H₂S sensing by Xue *et al*⁷¹ and formation of AuS by reaction of H₂S on the gold nanoparticles was also reported by Shirsat *et al*.⁷² Moreover, various types of complex reactions between ZnO and sulphur compounds (SO_x, H₂S, (NH₄)₂S and so on.) have been reported from surface chemistry studies on ZnO.^{73–76} Kim *et al*⁷⁷ reported the formation of ZnS on the surface of ZnO on exposure to H₂S gas at a temperature above 300°C. The XPS studies revealed that at temperature above 300°C, beside surface reaction with oxygen, H₂S also decomposes to form Zn-S bonds in ZnO; this change causes the formation of a shallow donor level and causes a drastic increase in conductivity. Wang *et al*⁷⁸ studied

the sensitivity of ZnO to H_2S gas in the temperature range of 100–450°C and reported the sulphuration of ZnO surface on exposure to H_2S gas. When the sensor was exposed to H_2S gas, the transformation of highly resistive ZnO into well-conducting ZnS led to the decrease of electrical resistance. The reactions in the response and recovery processes can be represented as follows:



The Gibbs free energy, enthalpy and entropy for both sulphuration and desulphuration were calculated by the group and the results showed that both reactions are spontaneous. We expect the same kind of sulphuration process in our ZnO thin film H_2S sensors along with the reaction of H_2S with oxygen adsorbates, thereby decreasing sensor resistance in the presence of H_2S gas.

Response and recovery times are important parameters for designing sensors for desired application. Response/recovery times are defined as the time required for absorption and desorption of the oxygen on, or from the sensor surface to reach the saturation or to reduce the conductivity back to the

baseline conductance. Response time of a sensor can vary from seconds to minutes, but a good sensor is the one that shows a short response and recovery time. In our work, response time of sensor was defined as time required for sensor resistance to reach 90% of maximum resistance. Recovery time was defined as time necessary for the sensor to return to 10% of its original resistance (before introduction of gas). Response and recovery time of ZnO sensor to 7 ppm NO_2 and 18 ppm H_2S gas at the temperature range of 100–225°C was recorded and is shown in figure 10a and b. At optimum temperature of 200°C, the response time of ZnO sensor was 6 and 10 s to NO_2 and H_2S gases, respectively. The recovery time recorded was 2.3 and 7 min to NO_2 and H_2S gases respectively. The response and recovery time obtained for ZnO sensor to NO_2 gas is comparable with earlier published results.^{44,68,79,80} Compared to NO_2 measurements it is seen that the recovery characteristics are very slow for H_2S measurements. This may be due to slow desulphuration process on the surface of sensors resulting in larger recovery time.

4. Conclusion

ZnO thin film sensors were fabricated by spray pyrolysis technique. The prepared films were annealed at 600°C overnight prior to gas sensing measurements. The XRD analysis confirmed the nanocrystalline nature of the annealed sensor. The average particle size was found to be 38 nm. The crystalline structure was found to be hexagonal wurtzite in nature. Surface morphological studies performed with SEM revealed closely packed arrangement of crystallites. Elemental analysis were performed using EDS. Raman spectroscopy studies confirmed the ZnO hexagonal wurtzite structure. Raman studies established the oxygen deficient nature of thin film sensor, which has an added advantage for gas sensing purposes. Gas sensing investigation of the prepared sensors was characterized with NO_2 and H_2S gases. Thin film sensors were found to be more selective to NO_2 gas at an optimum temperature of 200°C. For a 7 ppm concentration, the sensor sensitivity was 3.32 with a response and recovery time of 6 s and 2.26 min, respectively. It is expected that the response to H_2S arises due to changes in grain boundary resistance, while that to NO_2 arises due to changes in both intra-grain and grain boundary resistances. Oxygen vacancies in the lattice, as were also seen, enhance the sensor response. However, the exact details of these complicated surface reactions are yet to be fully understood. More detailed experimentation would be necessary to substantiate the suggestions speculated here. The results indicate that spray pyrolysis technique is a reliable method for the preparation of nanocrystalline zinc oxide films for gas sensor applications.

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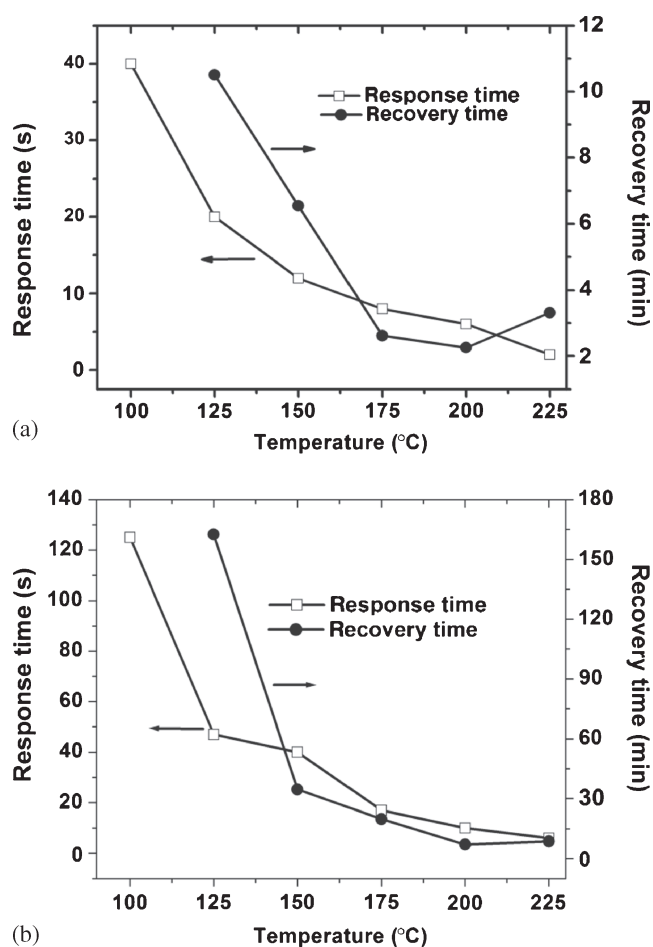


Figure 10. Response and recovery time of ZnO thin film sensor to (a) 7 ppm NO_2 gas (b) 18 ppm H_2S gas at different temperature.

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